

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: KIM, Hyun-Jae and KANG, Myung-Koo
 Assignee: SAMSUNG ELECTRONICS CO., LTD.
 Title: METHOD OF POLYCRYSTALLIZATION, METHOD OF
 MANUFACTURING POLYSILICON THIN FILM TRANSISTOR,
 AND LASER IRRADIATION DEVICE THEREFOR
 Int'l. Application No.: PCT/KR2003/002212 Int'l. Filing Date: 10/21/2003
 Application No.: Not Assigned Filing Date: Herewith
 Examiner: Not Assigned Group Art Unit: Not Assigned
 Docket No.: AB-1432 US

San Jose, California
 April 22, 2005

Mail Stop PCT
 Commissioner for Patents
 P.O. Box 1450
 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. § 1.97(b)

Dear Sir:

Pursuant to 37 C.F.R. §§ 1.56, 1.97 and 1.98, the documents listed on the accompanying PTO Form-1449 are called to the attention of the Examiner for the above-identified application. Copies of the documents are enclosed with the exception of any U.S. patents. The documents were cited by the Korean Patent Office in the International Search Report for International Application No. PCT/KR2003/002212, which is the international stage of the present application

Citation of the above documents shall not be construed as:

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2. a representation that a search has been made, other than as described above; or

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3. an admission that the information cited herein is, or is considered to be, material to patentability as defined in § 1.56(b).

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Respectfully submitted,



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U.S. Department of Commerce, Patent and Trademark Office		Atty. Docket No.	Application No.
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(Use several sheets if necessary)		KIM, Hyun-Jae and KANG, Myung-Koo	
		Filing Date	Group
		Herewith	Not Assigned

U.S. Patent Documents

*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA	US 5,302,230	04/12/1994	Ino et al.			
	AB	US 2001/0019863	09/06/2001	Yang			
	AC	US 2002/0083557	07/04/2002	Jung			
	AD	US 2002/0110962	08/15/2002	Wada et al.			
	AE						
	AF						
	AG						
	AH						
	AI						
	AJ						
	AK						

Foreign Patent Documents

							Translation	
		Document	Date	Country	Class	Subclass	Yes	No
	AL							
	AM							
	AN							
	AO							
	AP							

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

	AQ	Patent Abstracts of Japan, Publication No. 54-153745, 12/04/1979, 1 page
	AR	Patent Abstracts of Japan, Publication No. 56-047288, 04/28/1981
	AS	Patent Abstracts of Japan, Publication No. 60-247488, 12/07/1985

Examiner

Date Considered

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	AL						
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OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
	AQ	Patent Abstracts of Japan, Publication No. 01-214011, 08/28/1989					
	AR	Patent Abstracts of Japan, Publication No. 02-165880, 06/26/1990					
	AS	Patent Abstracts of Japan, Publication No. 03-235040, 10/21/1991					
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